



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the PATENT APPLICATION of

Byoung-tae k Lee et al.

Group Art Unit: 2823

Serial No.: 09/276,803

Examiner: N. Berezny

Filed: March 26, 1999

For: METHOD FOR MANUFACTURING CAPACITOR OF SEMICONDUCTOR
DEVICE HAVING DIELECTRIC LAYER OF HIGH DIELECTRIC CONSTANT

AMENDMENT

Honorable Assistant Commissioner for Patents
Washington, D.C. 20231

Date: August 10, 2001

Sir:

In response to the Office Action dated April 11, 2001, the period for response having been extended one (1) month to August 11, 2001, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

In the Abstract:

Please cancel the Abstract and replace with the Abstract attached herewith.

In the Claims:

Please cancel claim 8 without prejudice or disclaimer of the subject matter contained therein.